

## Nanoscopy of van der Waals heterostructures fabricated by the wet transfer method





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Introduction

Two dimensional crystals have been in the focus of scientific research for almost two decades, since the discovery of their first representative, graphene [1]. Among other properties which make these materials interesting for various applications ranging from tribology to optoelectronics, the possibility to combine them at will into vertical stacks, called van der Waals heterostructures (VdWhs), has opened the door to a world of new, equally interesting, and unique materials whose electronic and optical properties can be tailored by changing the VdWh constituents [1].

In this work we investigate VdWhs fabricated from 2D transition metal dichalcogenides (WS<sub>2</sub> and MoS<sub>2</sub>, in particular), which are considered to be strong candidates for various applications in the fields of optics and optoelectronics [2]. The fabrication of these heterostructures was done using a modified variant of the wet transfer method which has proven to be superior to the commonly used procedures in terms of its simplicity and quality of the produced VdWh [3]. The structural and optical properties of the VdWh fabricated by this method were thoroughly investigated by atomic force microscopy, Raman and photoluminescence spectroscopy.





Optical microscopy images of MoS<sub>2</sub>/WS<sub>2</sub> VdWh at two different positions with coresponding PL maps before and after temperature annealing

|           |           | ***** |
|-----------|-----------|-------|
| substrate | substrate |       |

remove the contaminants, but they diffuse into large clusters, so there are areas between the clusters where a good contact between monolayers is achieved.

## References

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## Conclusion

A modified variation of the wet transfer method to fabricate MoS<sub>2</sub>/WS<sub>2</sub> VdWh has been used and the heterostructures have been inspected using AFM, Raman and PL spectroscopy. The analysis of the results obitained by all the characterization methods shows that fabricated MoS<sub>2</sub>/WS<sub>2</sub> vertical heterostructures have relatively clean surfaces with low amount of PDMS residue and uniform PL and unchanged crystal structure which is the same as the crystal structure of the MoS<sub>2</sub> and WS<sub>2</sub> monolayers before the transfer. The main problem with the MoS<sub>2</sub>/WS<sub>2</sub> VdWh is the presence of trapped interlayer contaminants which can hinder the interaction between the MoS, and WS, monolayers. It has been found that the influence of the interlayer contaminants on the relevant optical properties of MoS<sub>2</sub>/WS<sub>2</sub> VdWh can be reduced by thermal annealing of the sample.

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